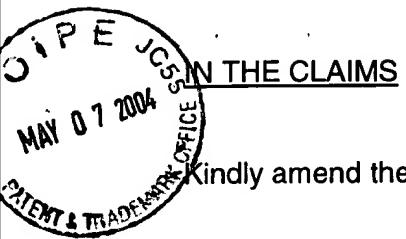


Please amend the above-identified patent application without prejudice as follows.

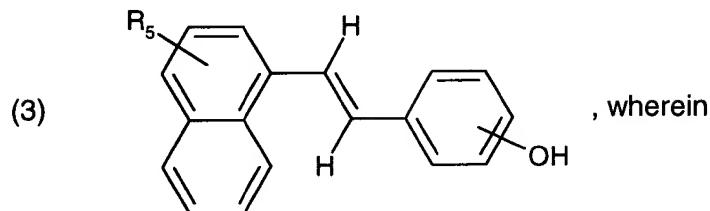


IN THE CLAIMS

Kindly amend the claims to read as follows.

Claims 1-15 (cancelled).

16. (original): A compound of formula



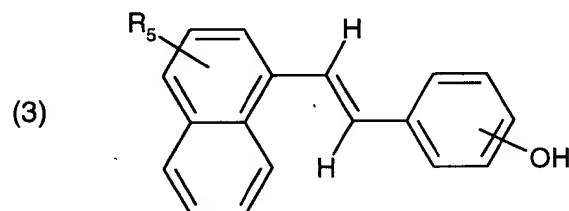
R₅ is hydrogen, halogen, hydroxy, C₁-C₁₆alkyl, C₁-C₁₆alkoxy, phenyl; C₁-C₃phenylalkyl; C₆-C₁₀aryloxy; amino; mono-C₁-C₅alkylamino; di-C₁-C₅alkylamino; or -NO₂.

17. (original): A compound according to claim 16, wherein

R₅ is hydrogen.

18-23 (cancelled).

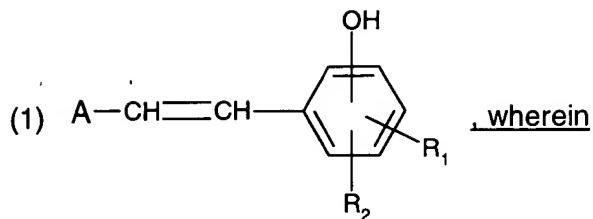
24. (currently amended): A method according to claim 18, wherein there is used a of antimicrobial treatment, deodorisation and disinfection of the skin, mucosa and hair, which comprises applying thereto an antimicrobiially effective amount of a hydroxystilbene compound of formula



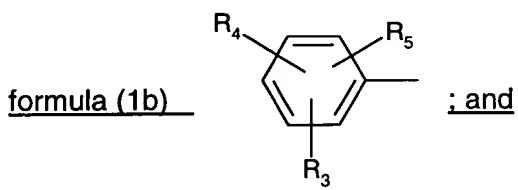
wherein R₅ is as defined in claim 18 hydrogen, halogen, hydroxy, C₁-C₁₆alkyl, C₁-C₁₆alkoxy, phenyl; C₁-C₃phenylalkyl; C₆-C₁₀aryloxy, amino, mono-C₁-C₅alkylamino, di-C₁-C₅alkylamino, or -NO₂.

25-31 (cancelled).

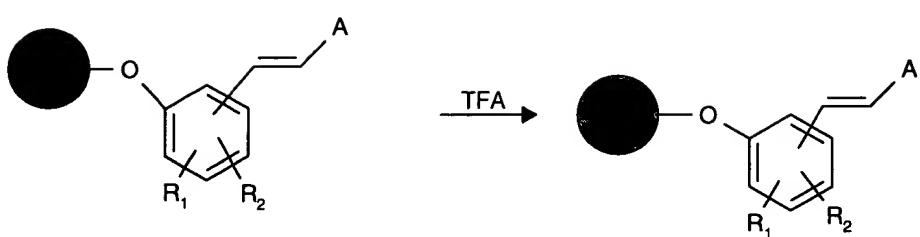
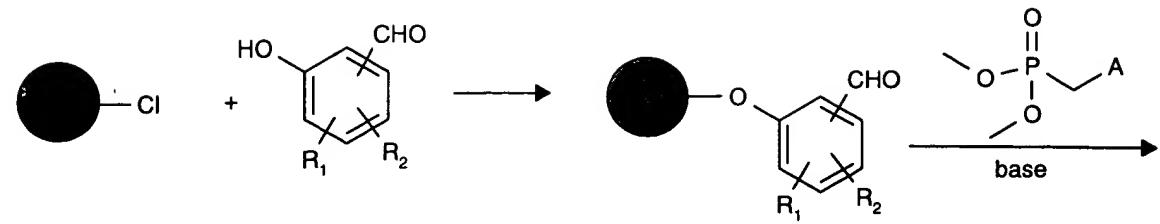
32. (currently amended): A process for the preparation of compounds of formula



A is a radical of formula (1a) ; or a radical of



R₁, R₂, R₃, R₄ and R₅ are each independently of the others hydrogen, halogen, hydroxy, C₁-C₁₆alkyl, C₁-C₁₆alkoxy, phenyl; C₁-C₃phenylalkyl; C₆-C₁₀aryloxy, amino, mono-C₁-C₅alkylamino, di-C₁-C₅alkylamino, or -NO₂ according to claim 18, which process comprises preparing them in a solid-phase synthesis using a trityl resin in accordance with the following scheme:



= trityl resin radical